

AF/1752

## BOX AF

RESPONSE UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE GROUP 1752 PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q58614

Kenichiro SATO, et al.

Appln. No.: 09/541,597

Group Art Unit: 1752

Confirmation No.: 4840

Examiner: R. ASHTON

Filed: April 3, 2000

For:

POSITIVE PHOTORESIST COMPOSITION FOR FAR ULTRAVIOLET

**EXPOSURE** 

## RESPONSE UNDER 37 C.F.R. § 1.116

## **MAIL STOP AF**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated January 12, 2004, please consider the remarks as submitted herewith on the accompanying pages.